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<b>SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT IN AN APPLICATION</b>		Application No. 10/822,625		Inventor Michael Krebs et al.	
		Title REACTIVE POLYURETHANE COMPOSITIONS WITH A LOW RESIDUAL MONOMER CONTENT			
		Filing Date 04/12/2004		Group Art Unit 1796	Docket No. H5395 US
<b>UNITED STATES PATENT DOCUMENTS</b>					
Examiner Initial	Cite No.	Document No.	Date	Name	
<b>FOREIGN PATENT DOCUMENTS</b>					
Examiner Initial	Cite No.	Document No.	Publication Date	Name	Translation
/P.N./		JP 2000-211295	08/02/200	Sekisui Chem Co. Ltd	X
/P.N./		JP 08-060129	03/05/1996	Bayer AG	X
/P.N./		JP 01-167323	07/03/1989	Bayer AG	X
/P.N./		JP 5-505846	08/26/1993	HB Fuller Licensing & Financing Incorporated	X
/P.N./		JP 2000-297130	10/24/2000	Mitsubishi Gas Chem Co Inc	X
/P.N./		JP 10-500715	01/20/1998	Henkel KGaA	X
/P.N./		WO 99/24486	05/20/1999	Henkel KGaA	
/P.N./		WO 01/40340	06/07/2001	Crompton Corporation	
<b>NON PATENT LITERATURE DOCUMENTS</b>					
Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
Examiner Initial	Cite No.				
Examiner /Patrick Niland/			Date Considered 06/18/2010		
<b>EXAMINER:</b> Initial if citation considered, whether or not citation is in conformance with MPEP §609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.					